



JPW B/A

AMENDMENT AFTER ALLOWANCE
EXPEDITED PROSECUTION - GROUP ART UNIT 2828

03500.013974.1

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
: Examiner: Davienne N. Monbleau
TADAHIRO OHMI ET AL.)
: Group Art Unit: 2828
Application No.: 09/985,707)
: Filed: November 6, 2001)
: For: LASER GAS SUPPLY PATH)
STRUCTURE IN AN EXPOSURE)
APPARATUS)

May 18, 2004

Mail Stop: Issue Fee
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

DO NOT ENTER
DM 9-15-04

AMENDMENT UNDER 37 C.F.R. § 1.312

Sir:

a) Introductory Comments

This application having been allowed, please amend the claims as follows: